The international journal & abstracting service for vacuum science & technology

VACUUM

SURFACE ENGINEERING, SURFACE INSTRUMENTATION & VACUUM TECHNOLOGY

Volume 48, 1997

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VACUUM

SURFACE ENGINEERING, SURFACE INSTRUMENTATION & VACUUM TECHNOLOGY

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The Item-Fee Code for this publication is: 0042-207X/98 $19.00+.00

Subscription Rates
Published monthly (3 volumes, 4 issues per volume)
Annual Institutional Subscription Rates 1998: Europe, The CIS and Japan 2697.00 Dutch Guilders. All other countries US$1550.00. Associated Personal Subscription Rates are available on request for those whose institutions are library subscribers. Dutch Guilder prices exclude VAT. Non-VAT registered customers in the European Community will be charged the appropriate VAT in addition to the price listed. Prices include postage and insurance and are subject to change without notice.
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Periodicals postage paid at Newark, NJ and additional entry points. *Vacuum* (ISSN 0042-207X) is published monthly, January to December in 3 volumes, by Elsevier Science Ltd., The Boulevard, Langford Lane, Kidlington, Oxford OX5 1GB, UK. The annual subscription in the USA is $1550.00. *Vacuum* is distributed by Mercury Airfreight International Ltd., 10 Camptown Road, Irvington, NJ 07111-1105. Postmaster: please send address changes to *Vacuum*, c/o Elsevier Science Regional Sales Office, Customer Support Department, 655 Avenue of the Americas, New York, NY 10010, USA.

Typeset in Great Britain by BPC Digital Data Ltd. Printed by BPC-AUP Aberdeen Ltd.

Publishing Office: *Elsevier Science Ltd, Bampfylde St, Exeter EX1 2AH, UK. Tel: (+1392) 251558 Fax: (+1392) 425370*
Advertising Offices: *The Boulevard, Langford Lane, Kidlington, Oxford OX5 1GB, UK. Tel: (+1865) 843000 Fax: (+1865) 843010*
Elsevier Science Inc., 655 Avenue of the Americas, New York, NY 10010, USA.

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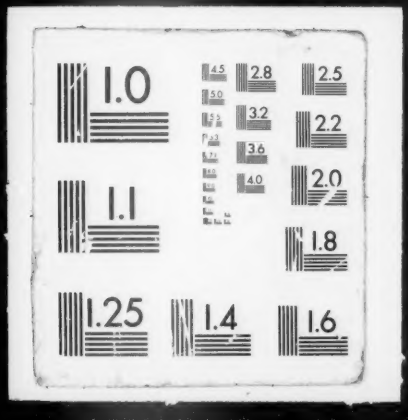
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